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(54) **FILM FORMING METHOD AND BASE MATERIAL**

material.

(57) Abstract:

PROBLEM TO BE SOLVED: To provide a method of forming a film having excellent forming property and workability even on the surface of a base material surface having a complicated shaped surface in the film forming method using a photosetting type coating

SOLUTION: The film forming method includes a process performed by applying the photosetting type coating material on the base material, hardening the resultant coating film with the irradiation with light without coating the resultant film and further irradiating with light.

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